

\	Hits	Search Text	DBs
20	84	((resist or photoresist) near29 resin near36 (surfactant or (surface near9 active near12 agent))) and (crosslink\$4 not (cross\$4link\$4 near4 agent))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
22	436	((composition or thicken\$4 or enhanc\$4 or material) near12 resin\$4 near16 (surfactant or (surface near9 active near12 agent))) and (solvent not crosslink\$4 not (cross\$4link\$4 near4 agent) not sensit\$4 not (base near9 compound) not (photoacid or photoactive)) and (non\$4ionic and anionic and cationic)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB